IN THE SPECIFICATION:

The specification as amended below with replacement paragraphs shows added text with <u>underlining</u> and deleted text with <u>strikethrough</u>.

Please REPLACE paragraph [0051] on pages 9-10 with the following amended paragraph:

[0051] As shown in FIG. 6B, the mask 110 is clamped and subjected to a tension in directions x and y. Here, the same tension can be applied in directions x and y. However, it is preferable that the four sides are subjected to optimal tensions +Px1 to +Px5, -Px1 to -Px5, +Py1 to +Py6, and -Py1 to -Py6, respectively. In this case, as shown in FIG. 7A, there is no deviation because the total pitches-pitch Pt between two outermost lines 114 and 115 are-is uniform. As shown in FIGS. 7B and 7C, the total pitch Pt may have a deviation (Ptma-(Δ Pt = Ptmax - Ptmin). As shown in FIGS. 7B through 7D, a line deviation (Δ X) may occur. Consequently, the application of different tensions for different sides of the mask can reduce the deviation of the total pitch and the line deviation.